

# $V_{OC}$ impact of orientation-dependent $\chi$ in anisotropic PV absorbers

Rupak Chakraborty<sup>1</sup>

David Berney Needleman<sup>1</sup>, Kelsey Doolittle<sup>1</sup>,  
Niall M. Mangan<sup>1</sup>, Vera Steinmann<sup>1</sup>, Jeremy  
R. Poindexter<sup>1</sup>, Alex Polizzotti<sup>1</sup>, Chuanxi  
Yang<sup>2</sup>, Roy G. Gordon<sup>2</sup>, and Tonio  
Buonassisi<sup>1</sup>

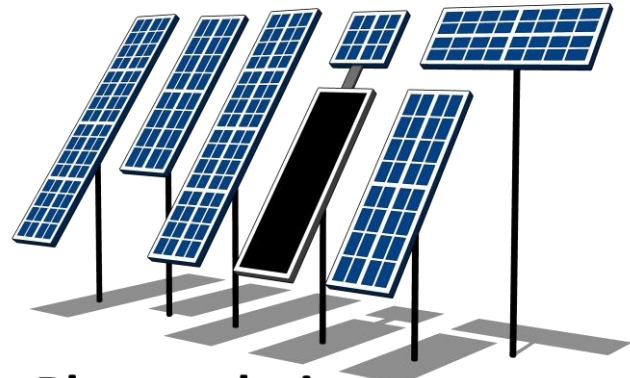
<sup>1</sup>Massachusetts Institute of Technology

<sup>2</sup>Harvard University

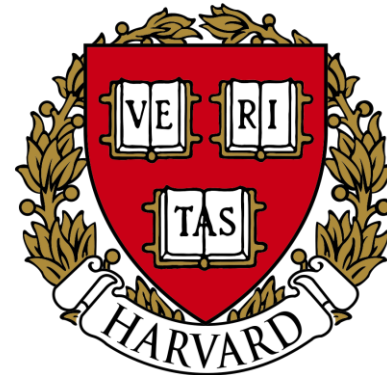
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Symposium NN

December 3, 2015

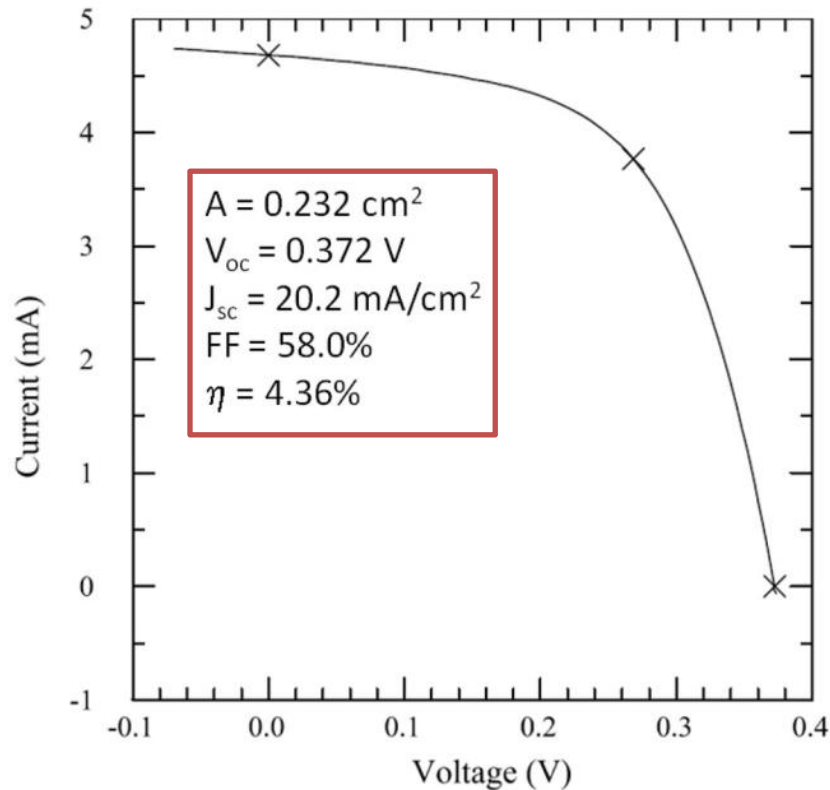


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# $V_{OC}$ deficit in SnS

- Many PV material systems are plagued by low  $V_{OC}$
- CZTS,  $WS_2$ ,  $FeS_2$ , **SnS**

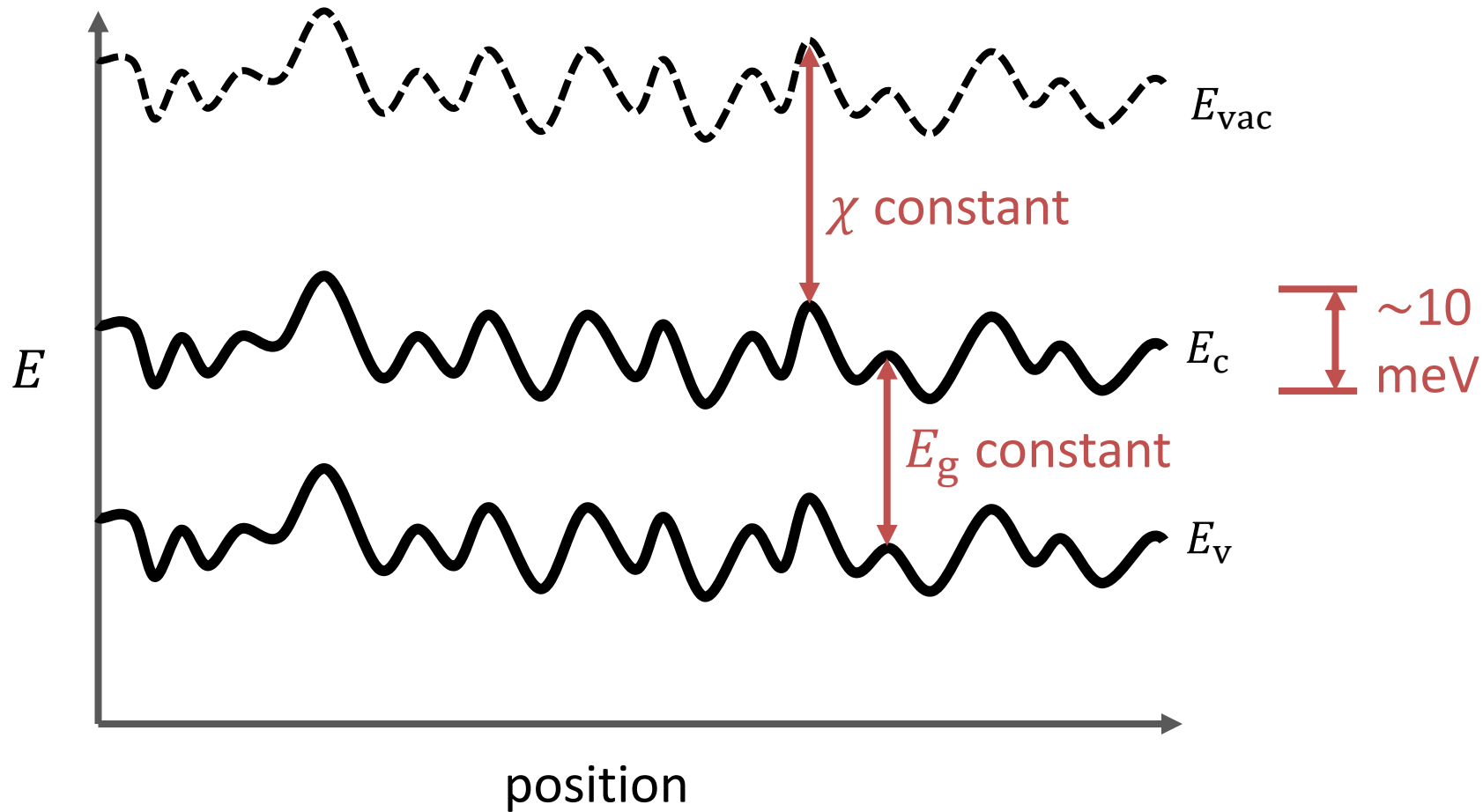


$$V_{OC}^{\text{deficit}} = \frac{E_g}{q} - V_{OC}$$
$$= 728 \text{ mV}$$

What causes low  $V_{OC}$ ?

# Band fluctuations: constant $\chi$

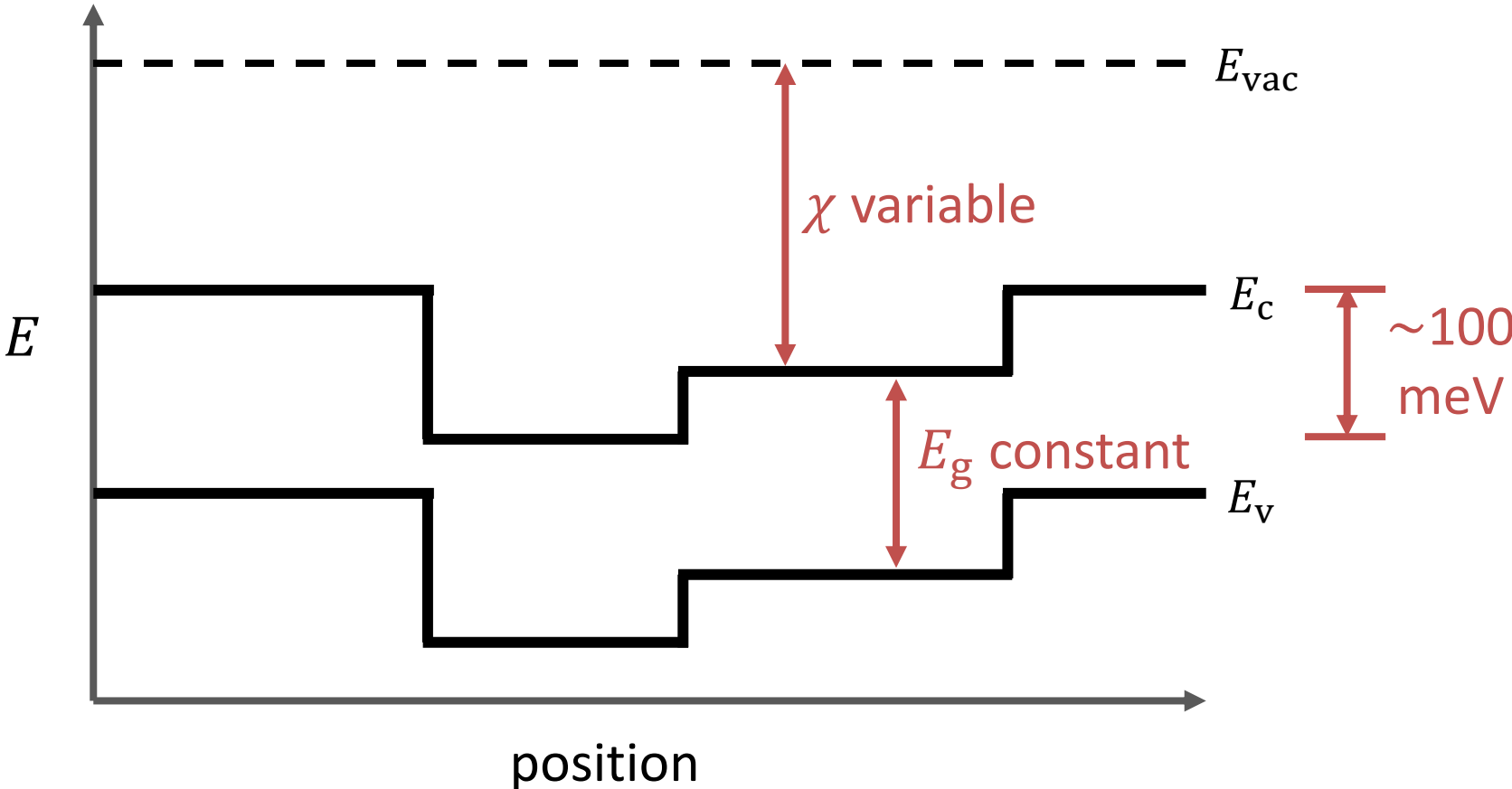
- $V_{OC}^{\text{deficit}}$  significantly influenced by electrostatic potential fluctuations<sup>1,2</sup>



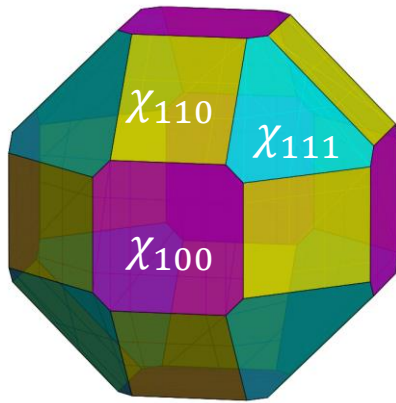
<sup>1,2</sup>J.H. Werner *et al.*, Thin Solid Films 480-481, 399 (2005).

<sup>1,2</sup>Gokmen *et al.*, Applied Physics Letters 103 (2013)

# Band fluctuations: variable $\chi$

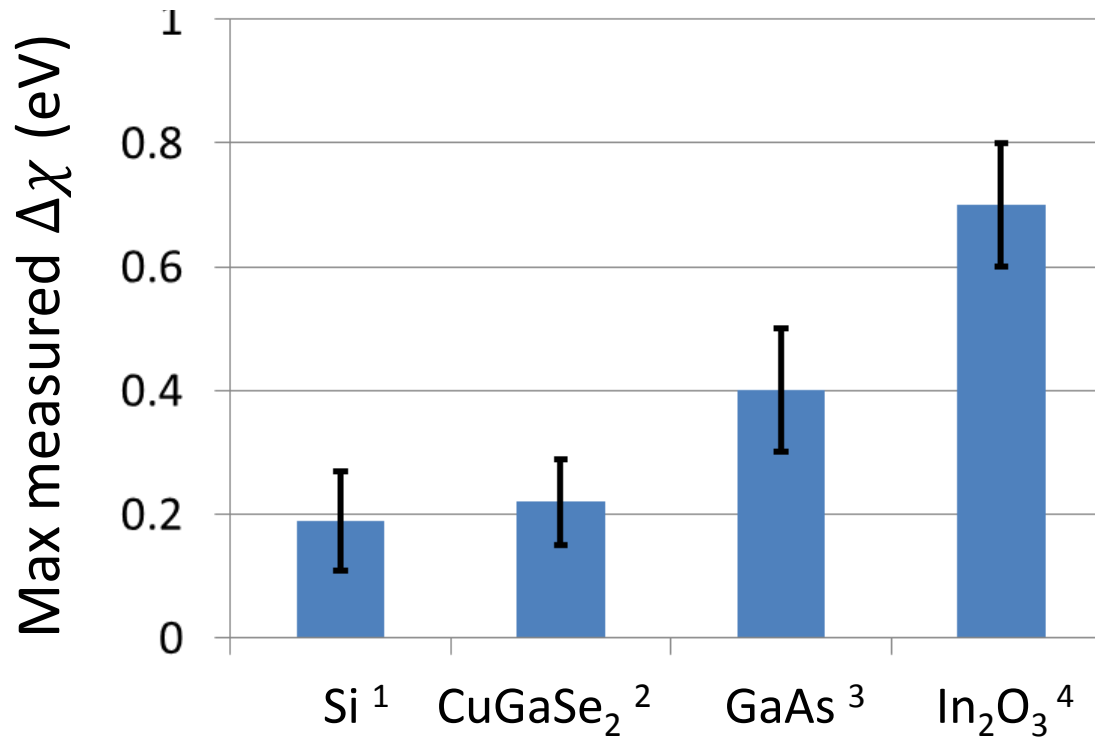


# Surfac



# χ-dependence of electron affinity

$$\Delta\chi = \chi_{hkl} - \chi_{h'k'l'}$$



Wulff construction: Zucker *et al.*, *Journal of Materials Science* 47:8290-8302 (2012).

<sup>5</sup>V. Stevanović *et al.*, *Appl. Phys. Lett.* 104, 211603 (2014).

<sup>1</sup>J.W. Keister *et al.*, *J. Vac. Sci. Technol. B* 17, 1831 (1999).

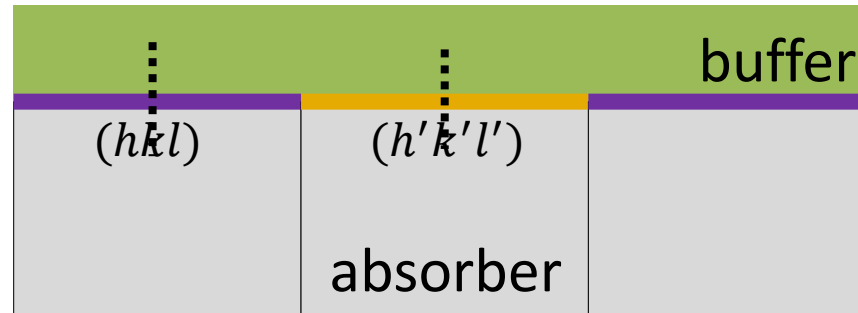
<sup>2</sup>S. Sadewasser *et al.*, *Appl. Phys. Lett.* 80, 2979 (2002).

<sup>3</sup>W. Ranke, *Phys. Rev. B* 27, 7807 (1983).

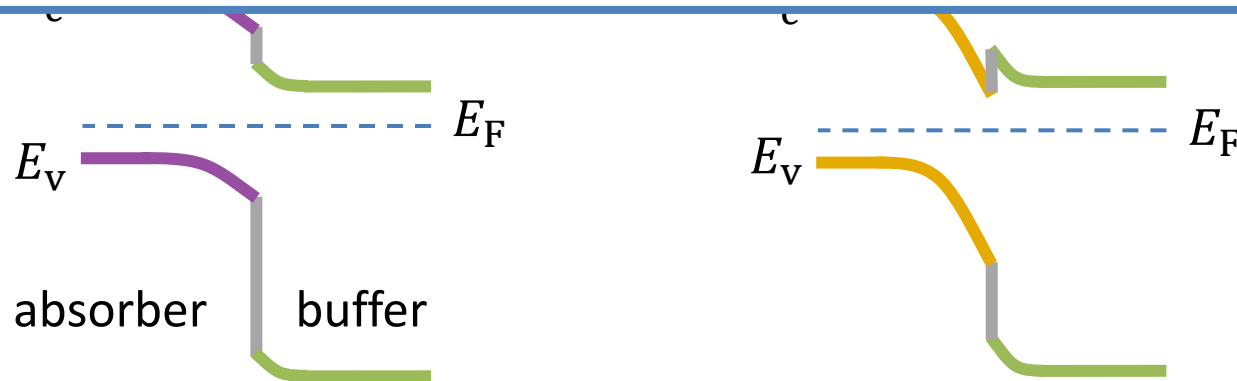
<sup>4</sup>M. Hohmann *et al.*, *J. Phys. Condens. Matter* 23, 334203 (2011).



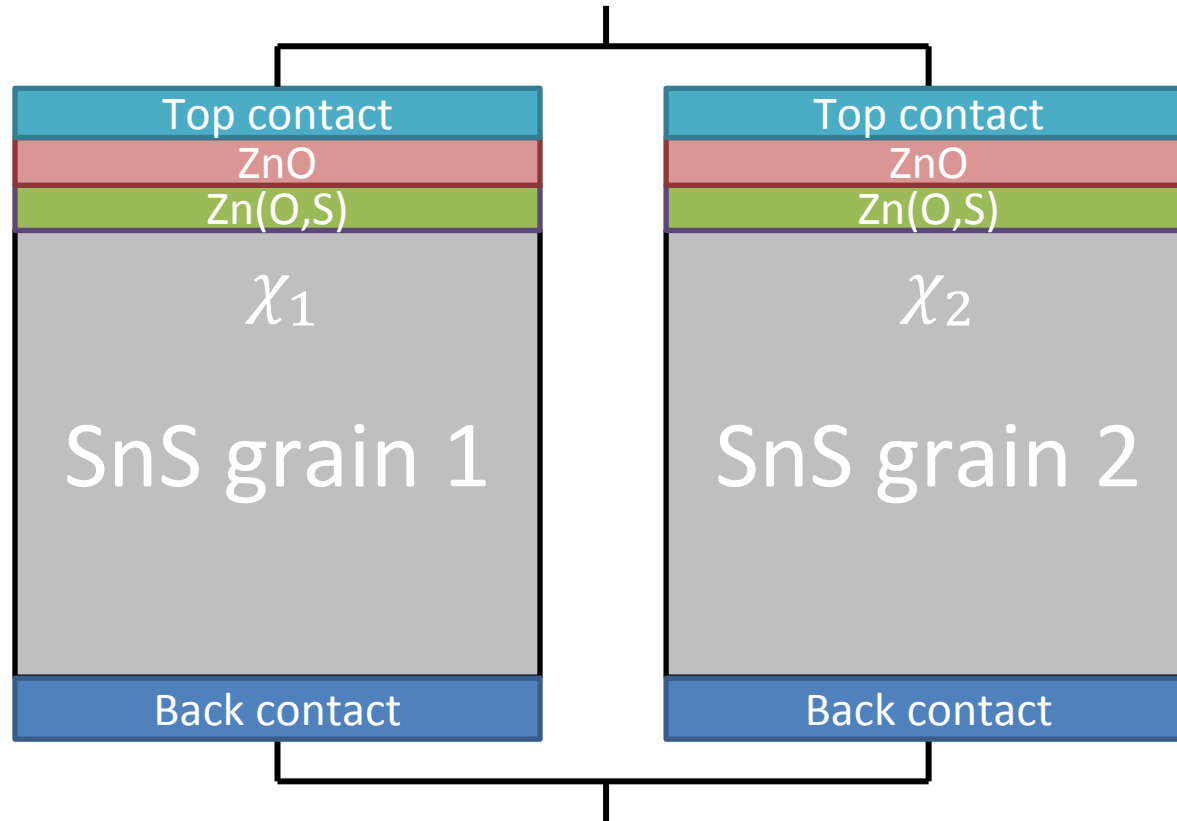
# Lateral CBO variation due to grain orientation



What is the impact of orientation-dependent electron affinity on SnS device performance?



# Simple test case: two-grain model

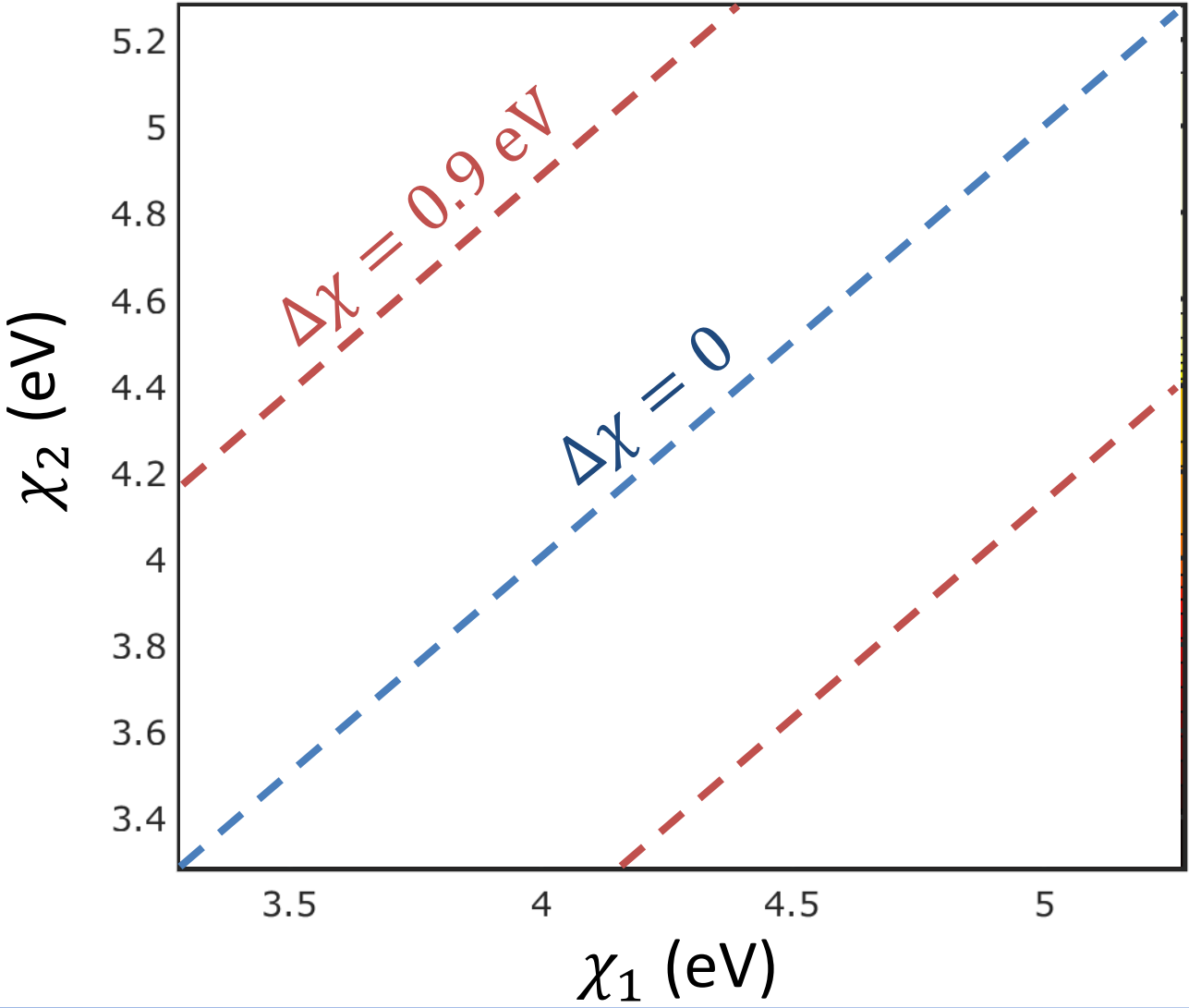


Single stack previously modeled in SCAPS 1D<sup>1</sup>

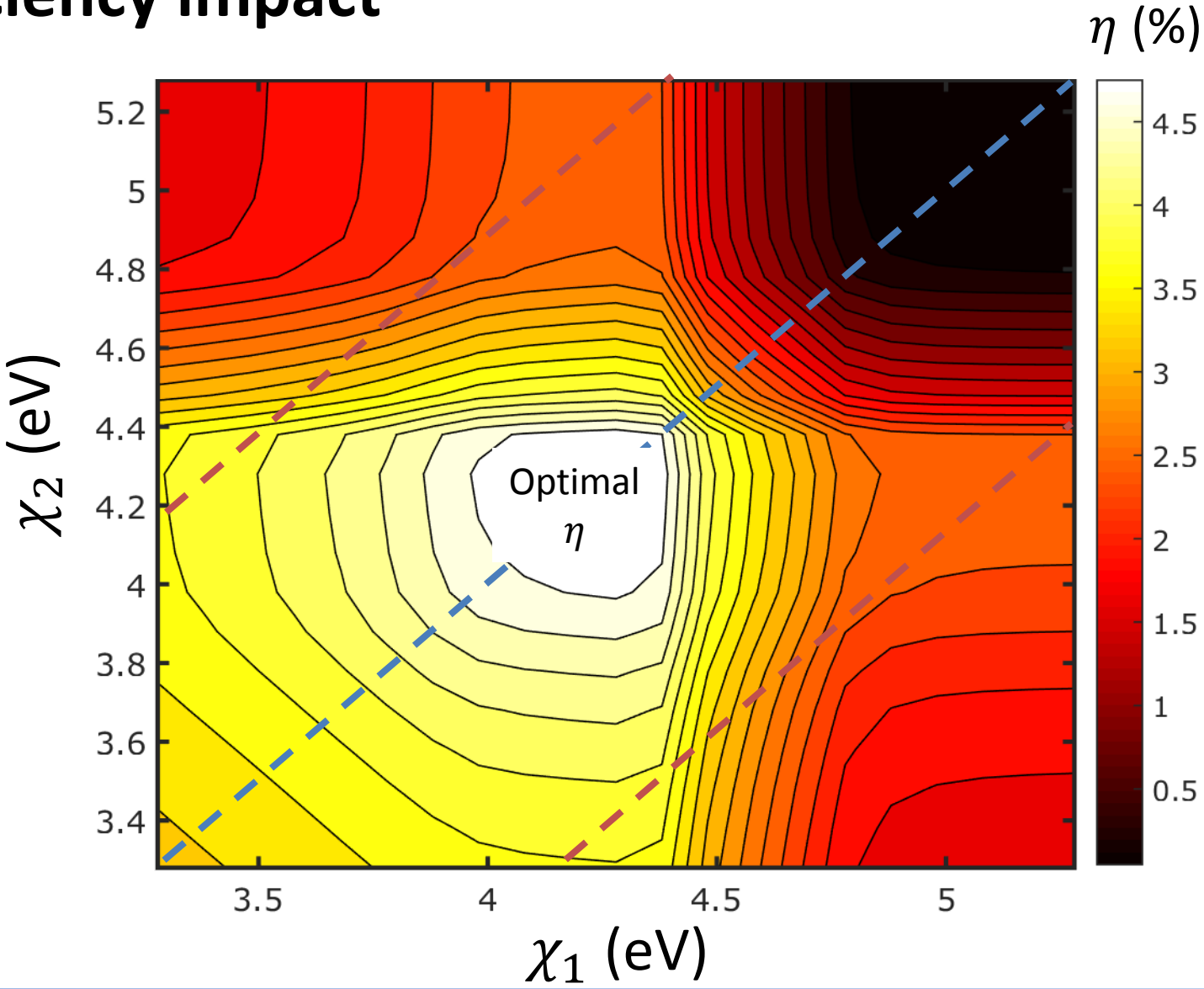
<sup>1</sup>Mangan *et al.*, J. Appl. Phys. 118, 115102 (2015).



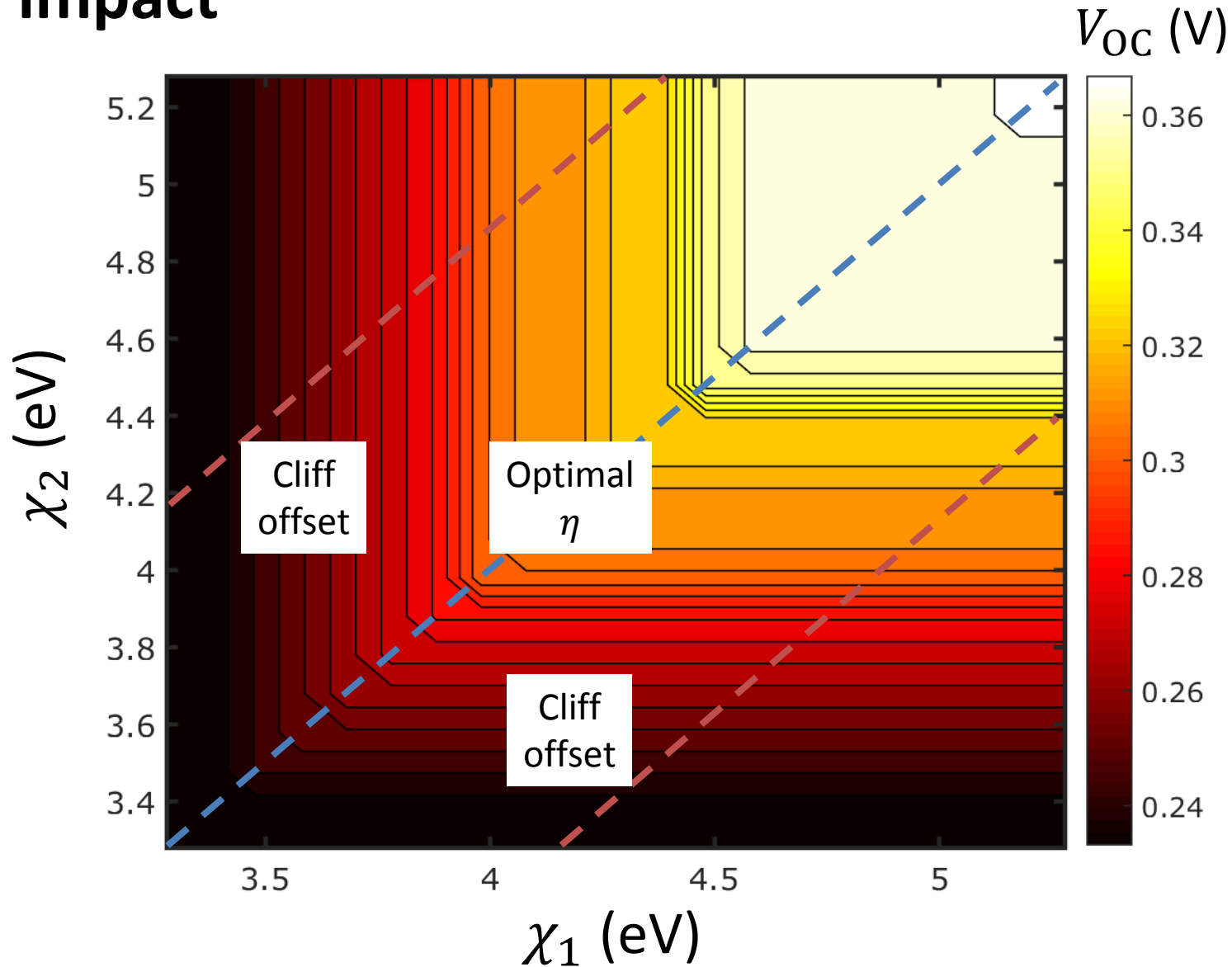
# Electron affinity parameter space



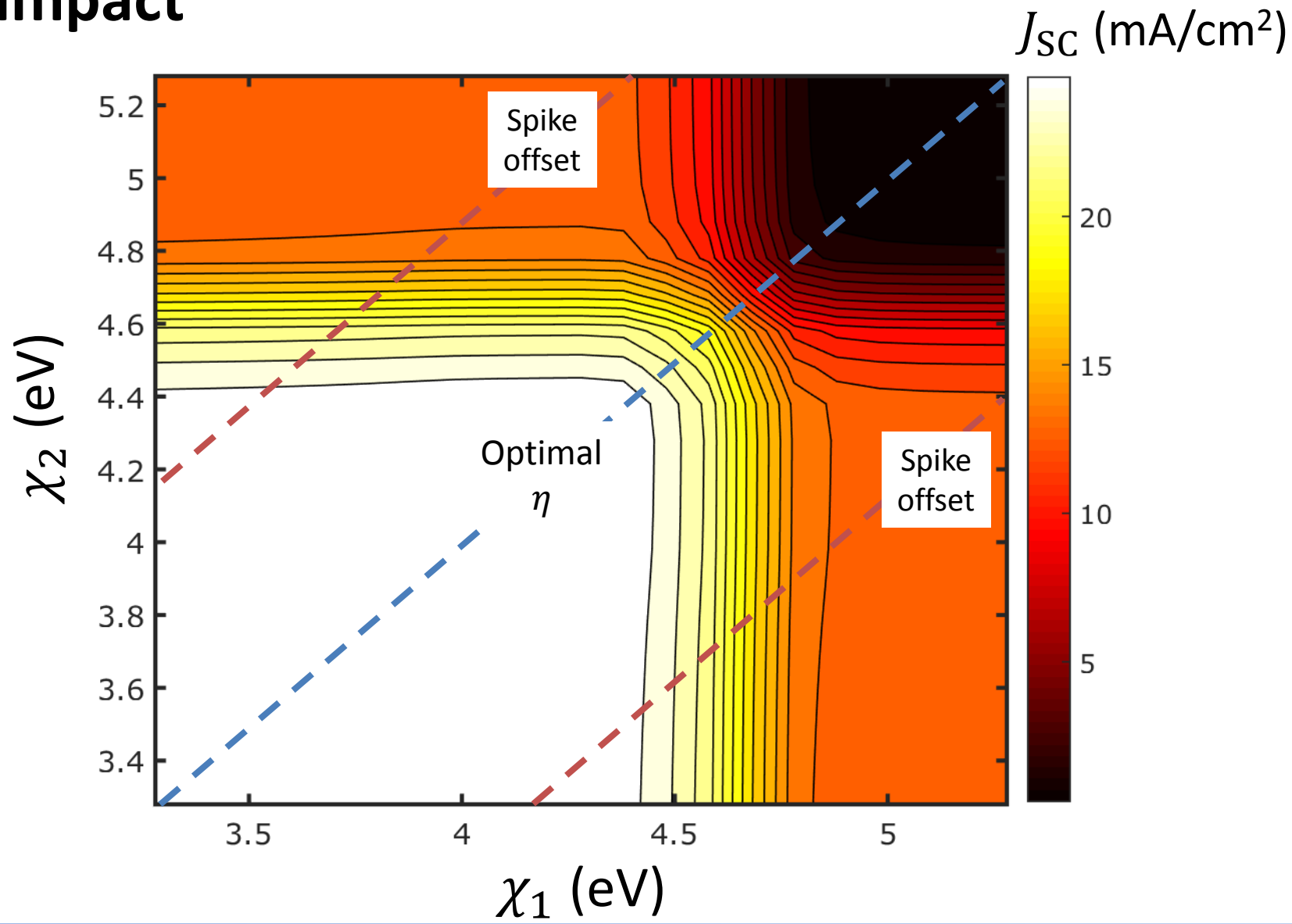
# Efficiency impact



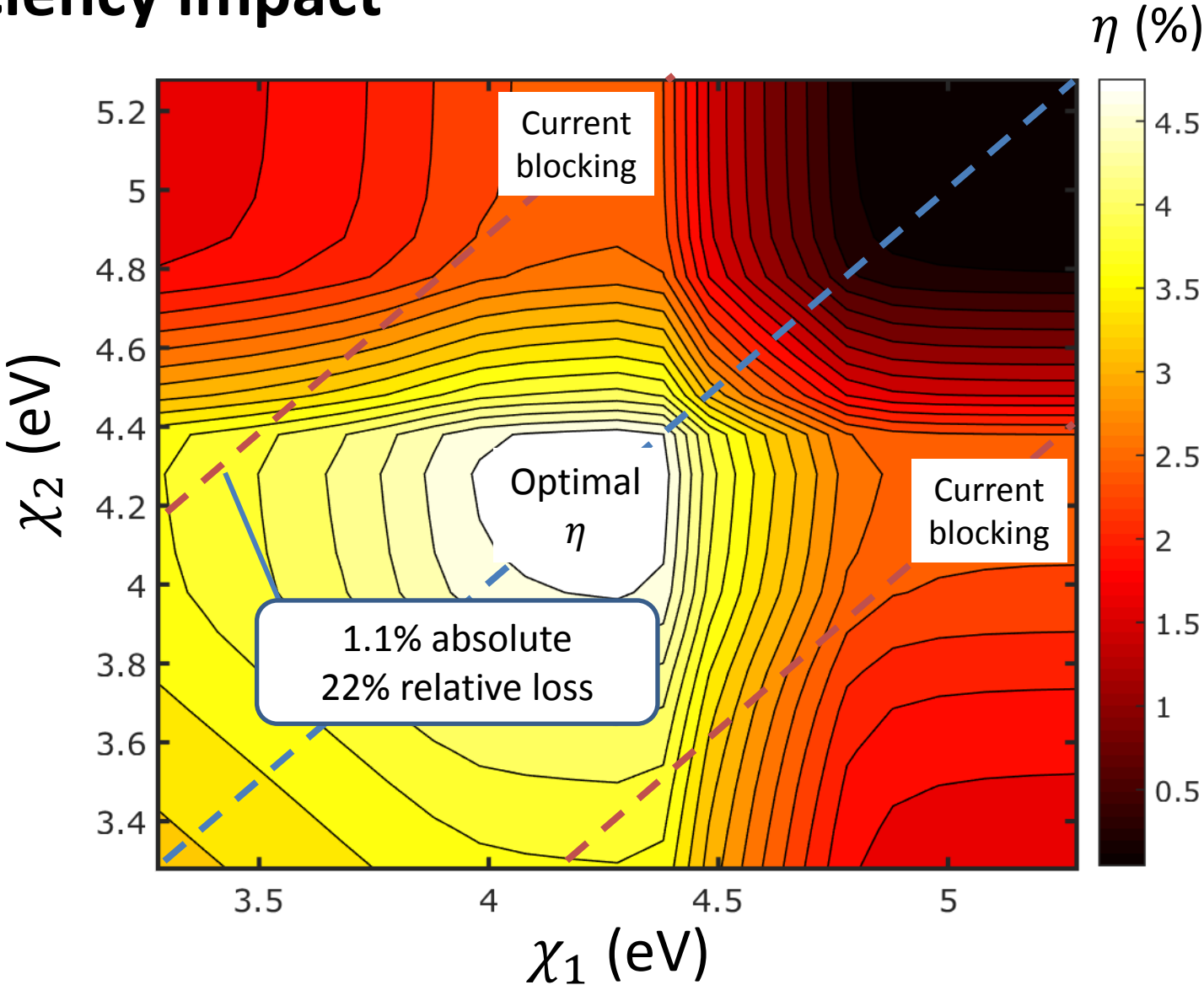
# $V_{OC}$ impact



# $J_{SC}$ impact



# Efficiency impact



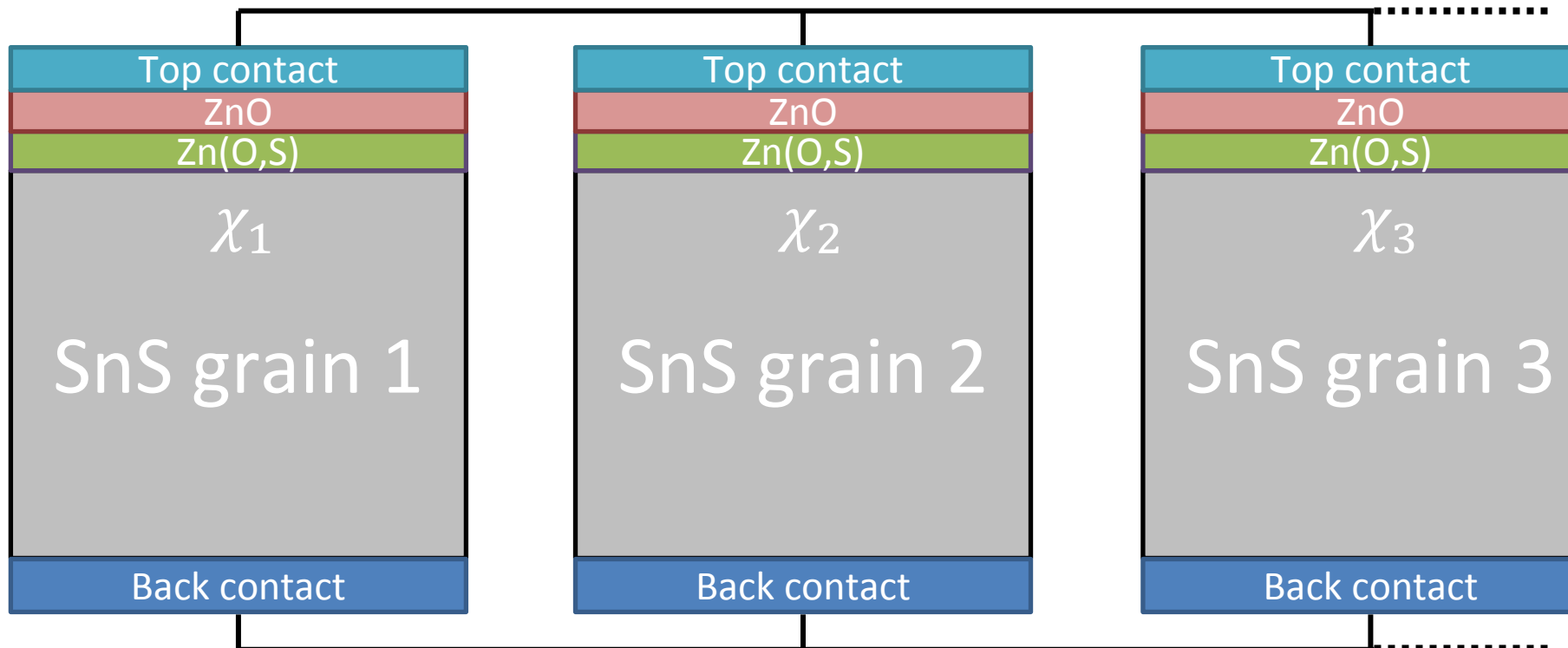
# Summary

- Abrupt lateral fluctuations in  $\chi$  are expected in SnS due to orientation dependence
- Current blocking is worst effect
  - Avoided by optimizing buffer layer
  - $V_{OC}$  still reduced because of cliff offset
  - 22% relative loss in efficiency for  $\Delta\chi = 0.9$  eV



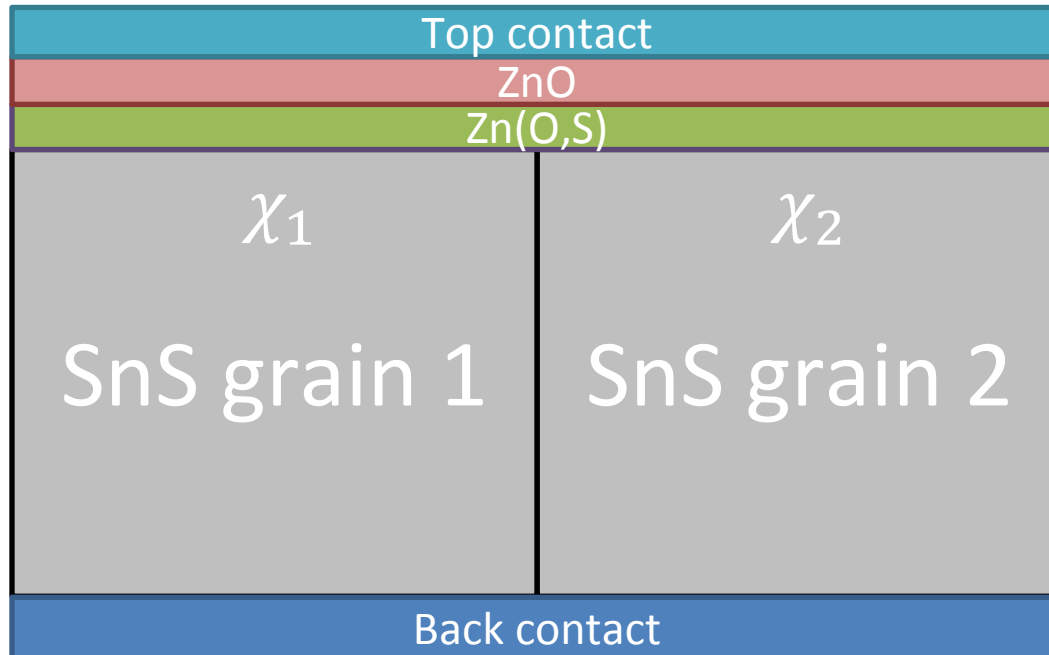
# Further work

- Confirm  $\chi(hkl)$  in SnS experimentally
- >2 grains in parallel



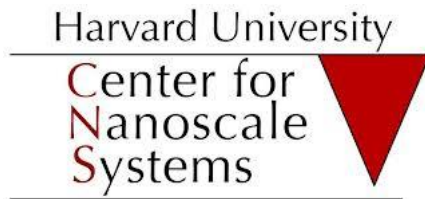
# Further work

- Confirm  $\chi(hkl)$  in SnS experimentally
- >2 grains in parallel
- Simulation accounting for 2D carrier flow



# Acknowledgments

- PVLab at MIT
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# Thank you!

